## **Transmutation Reactions Induced by Deuterium Permeation through Nano-structured Pd Multilayer Thin Film**

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## **1. Introduction**

## **Merits of Our Transmutation Method**

## Conventional Transmutation

Requires a large apparatus such as an accelerator and a nuclear reactor

## Permeation Induced Transmutation

Nuclear Transmutation can be induced by deuterium permeation through our original nanostructured Pd multilayer film



## **D**<sub>2</sub> gas permeation through nano-structured Pd complex



## **Reactions observed so far in MHI**



## 1)Alkali metals; Electron Emitter 2)2d, 4d, 6d; α capture reactions

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 $d^{4d(2\alpha)} \rightarrow \frac{141}{50} P$ 

 ${}^{4d(2\alpha)}_{38}Sr \rightarrow {}^{96}_{42}Mo$ 

 $^{138}_{56}Ba \rightarrow ^{150}_{62}Sm$ 

 $^{137}_{56}Ba \xrightarrow{6d(3\alpha)}{62} ^{149}Sm$ 

 ${}^{44}_{20}Ca \xrightarrow{2d(\alpha)}{}^{48}_{22}Ti$ 

 $^{184}_{74}W \xrightarrow{2d(\alpha)}_{76}Os$ 

 $4d(2\alpha)$ 

 $^{133}_{55}Cs$ 

## **Potential Applications**

## **1) Nuclear Transmutation** of Radioactive Waste



## 2) **Production of Rare Metals**

etc...

Generator



## 2. Original Experimental Method and Results



#### **Experimental apparatus with XPS**





#### **Transmutation of Cs into Pr**



Atomic Number +4 Mass Number +8







## Mass Number Correlation between Ba and Sm





# **3.** *In-situ* Measurement of Transmutation of Cs into Pr

#### Photo of the *in-situ* Experimental Setup





Experimental setup for in-situ measurement at SPring-8, which is one of the largest synchrotron radiation facilities. This setup enables us to observe elemental changes during D2 gas permeation by XRF (X-ray fluorescence spectrometry).

## In-situ Measurement Set-up at Spring-8



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## **Confirmation of Pr by** *in-situ* measurement



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## 4. Depth and Surface distribution of Transmuted Products



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## **Detection of Localized Pr**



#### **Further smaller beam analysis of Pr**



#### 100 µm beam;SP-24



Smaller X-ray beam provides **more localized Pr distribution.** 

#### 50 µm beam;SP-24



## **Existence of hot spots?**





## **5. Role of CaO**

D<sup>+</sup> Ion beam bombardment on metal target



## Experimental Apparatus



#### **Deuterium Density measured by D+ Ion Bombardment**

U₅(eV)



## **Effect of Intermediate Layer**





## 6. Transmutation of W into Pt or Os

## **Experimental Procedure**





#### **Transmutation of W into Pt or Os**



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Counts



## 7. Increase of Products using an Electrochemical Method

## **Pr** Dependence on D<sub>2</sub> gas pressure





#### **Experimental Apparatus aiming Increase of D Density**





## Cs<sup>+</sup> Ion Implantation to Pd/CaO/Pd film





## SIMS Analysis; E006 Wide Spectra







## ICP-MS Analysis; E006 Wide Spectra



## **ICP-MS Analysis; E006**



SIMS (point) and ICP-MS (all surface) gave similar results

Different Tendency from D<sub>2</sub> gas permeation

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## **Consideration on Compound Species**

## **Possible compounds for mass 140**

<sup>138</sup> Ba(71.7%)D	<sup>133</sup> Cs (100%) <sup>7</sup> Li (92.4%)	<sup>110</sup> Pd <sup>30</sup> Si(3.1%)
<sup>106</sup> Pd <sup>34</sup> Si(4.3%)	<sup>109</sup> Ag(48.1%) <sup>31</sup> P(100%)	<sup>104</sup> Pd <sup>36</sup> Ar(0.33%)
<sup>102</sup> Pd <sup>38</sup> Ar(0.06%)	<sup>110</sup> Pd <sup>28</sup> Si(92.3%)D	<sup>108</sup> Pd <sup>30</sup> Si(3.1%)D
<sup>105</sup> Pd <sup>33</sup> Si(0.8%)D	<sup>102</sup> Pd <sup>36</sup> Si(0.02%)D	<sup>102</sup> Pd <sup>36</sup> Ar(0.3%)D

## **Possible compounds for mass 139**

<sup>137</sup> Ba(11.2%)D	<sup>133</sup> Cs (100%) <sup>6</sup> Li (7.6%)	<sup>110</sup> Pd <sup>29</sup> Si(4.7%)
<sup>106</sup> Pd <sup>33</sup> Si(0.8%)	<sup>104</sup> Pd <sup>35</sup> Cl(75.8%)	<sup>102</sup> Pd <sup>37</sup> Cl(24.2%)
<sup>110</sup> Pd <sup>27</sup> Al(100%)D	<sup>106</sup> Pd <sup>31</sup> P(100%)D	<sup>105</sup> Pd <sup>32</sup> S (94.9%)D
<sup>104</sup> Pd <sup>33</sup> Si(0.8%)D	<sup>105</sup> Pd <sup>32</sup> Si(94.9%)D	<sup>102</sup> Pd <sup>35</sup> Cl(75.8%)D

Not explained consistently by these compounds



## 8. Replication Experiments





Presented at 17th International Conference on Condensed Matter Nuclear Science, Aug.12-17, 2012, Deajon, Korea



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## **Concluding Remarks**

- 1. Low energy nuclear transmutations from Cs into Pr, Ba into Sm and W into Pt or Os have been observed in the Pd complexes, which are composed of Pd and CaO thin film and Pd substrate, induced by D<sub>2</sub> gas permeation.
- 2. Experimental data that indicates the presence of transmutation have been accumulated and experimental conditions for inducing low energy transmutation reactions are gradually becoming clear, although systematic experimental study is still insufficient.
- 3. Replication experiments have been performed by some researchers and similar results have been obtained. Potential applications would be expected for innovative nuclear transmutation method of radioactive waste and a new energy source.

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